Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	(liquid wet immers\$3) with etch\$3 with substrate with (cavity opening recess trench groove) with ((side near wall) sidewall) with (adjacent near angle)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:40
L2	20	(liquid wet immers\$3) with etch\$3 with substrate with (cavity opening recess trench groove) with ((side near wall) sidewall) with angle	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:19
L3	12	(liquid wet immers\$3) with etch\$3 with substrate with (cavity opening recess trench groove) with ((side near wall) sidewall) with angle and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:14
L4	0	(cavity opening recess trench groove) with (four near ((side near wall) sidewall)) with (adjacent near angle) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:29
L5	17	(cavity opening recess trench groove) with ((side near wall) sidewall) with (adjacent near angle) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:36
L6	176	(cavity opening recess trench groove) with ((side near wall) sidewall wall side) with (adjacent near angle) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:37
L7	4	(cavity opening recess trench groove) with ((side near wall) sidewall wall side) with different with (adjacent near angle) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:38

L8	3	(cavity opening recess trench groove) with ((side near wall) sidewall wall side) with angle with rhombus and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:40
L9	229	(cavity opening recess trench groove) with rhombus with shap\$3 and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:40
L10	0	9 and (liquid wet immers\$3) with etch\$3 with substrate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:41
L11	23	9 and etch\$3 with substrate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:53
L12	3	11 and (wet with etch\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 12:53
L13	4	((liquid wet isotropic immers\$3) with etch\$3 with substrate) and ((cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:22
L14	0	(liquid with bath with immers\$3 with substrate with (cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:23

L15	0	(immers\$3 with substrate with (cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	NO	2006/09/01 13:24
L16	5	(immers\$3 with substrate) and ((cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:21
L17	9	immers\$3 and etch\$3 and substrate and ((cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:12
L18	2589	438/498,745,747,753.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:52
L19	0	18 and ((cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:52
L20	194	18 and immers\$3 and etch\$3 and substrate and (cavity opening recess trench groove) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:58
L21	6	18 and immers\$3 with etch\$3 with substrate with (cavity opening recess trench groove) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:56

L22	1	21 and (filter diplaxer resonator)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:57
L23	1	21 and (filter diplexer resonator)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:13
L24	12230	immers\$3 and etch\$3 and substrate and (cavity opening recess trench groove) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON '	2006/09/01 13:58
L25	3460	24 and (filter diplexer resonator)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 13:58
L26	2	25 and ((cavity opening recess trench groove) with rhombus) and @ad<"20021227"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:10
L27	102	((bergstedt near leif) (gevorgian near spartak) (gustafsson near marica)).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:11
L28	1	27 and immers\$3 and etch\$3 and substrate and ((cavity opening recess trench groove) with rhombus)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:12

L29	2	27 and immers\$3 and etch\$3 and substrate and (cavity opening recess trench groove)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:12
L30	33	27 and (filter diplexer resonator)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:14
L31	15	"5821836"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/01 14:14
L32	3	(immers\$3 and substrate and etch\$3 and (cavity opening recess trench groove) and (sidewall (side near wall)) and angle).clm.	US-PGPUB	OR	ON	2006/09/01 14:22